

Notice of References Cited	Application/Control No. 10/644,827		Applicant(s)/Patent Under Reexamination FUKUDA ET AL.	
	Examiner Ryan Lepisto		Art Unit 2883	Page 1 of 1

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*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
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*	B	US-2003/0035640	02-2003	Dugan et al.	385/124
*	C	US-6,154,593	11-2000	Miura et al.	385/123
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	M	US-			

FOREIGN PATENT DOCUMENTS

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NON-PATENT DOCUMENTS

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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.